PATENT COOPERATION TREATY

PCT

INTERNATIONAL SEARCH REPORT

(PCT Article 18 and Rules 43 and 44)

Applicant's or agent's file reference				ational Search Report
P2001,0126W0	ACTION	Form PCT/ISA/22	0) as well as, where	applicable, Item 5 below.
International application No.	International filing date (day	/month/year)	(Earliest) Priority D	Pate (day/month/year)
PCT/EP 02/02030	25/02/200)2	23/	/02/2001
Applicant	<u></u>			
INFINEON TECHNOLOGIES AG				
This International Search Report has been according to Article 18. A copy is being to			brity and is transmitti	ed to the applicant
This international Search Report consists	of a total of 3	sheets.		
	a copy of each prior art docur		eport.	
	·			
1. Basis of the report				
a. With regard to the tanguage, the tanguage in which it was filed, un			s of the international	application in the
the International search w Authority (Rule 23.1(b)).	vas carried out on the basis of	a translation of the	e international applic	cation furnished to this
b. With regard to any nucleotide er was carried out on the basis of the	id/or amino acid sequence o	disclosed in the int	ernational applicatio	n, the international search
——————————————————————————————————————	onal application in written form) <u>.</u>		
filled together with the inte	emational application in compl	uter readable form		
lumished subsequently to	o this Authority in written form.			
furnished subsequently to	o this Authority in computer rea	adble form.		
	bsequently furnished written s as filed has been furnished.	equence listing do	es nat go beyond th	e disclosure in the
the statement that the inf furnished	ormation recorded in compute	r readable lorm is	identical to the writte	en sequence listing has been
2. Certain claims were fou	ind unsearchable (See Box I)	١.		
3. Unity of Invention is lac		•		
4. With regard to the title,				
X the text is approved as s	ubmitted by the applicant.			
the text has been establis	shed by this Authority to read	as follows:		
5. With regard to the abstract,				
the text has been establi	ubmitted by the applicant. shed, according to Rule 38.2(t e date of mailing of this Interni	b), by this Authorit ational search rep	y as it appears in Bo ort, submit comment	x III. The applicant may, is to this Authority.
6. The figure of the drawings to be put	_		3_	
as suggested by the app		-		None of the figures.
because the applicant fa	_		لين	
	r characterizes the invention.			

INTERNATIONAL SEARCH REPORT

International Application No PCT/EP 02/02030

A. CLASSIFICATION OF SUBJECT MATTER IPC 7 H01L21/3213

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

inimum documentation searched (classification system followed by classification symbols) IPC 7 H01L

Documentation searched other than minimum documentation to the extent that such documents are included. In the fields searched

Electronic data base consulted during the International search (name of data base and, where practical, search terms used)

PAJ, EPO-Internal

C. DOCUMENTS CONSIDERED	TO	BE RELEVANT
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Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 6 159 863 A (CHEN ET AL) 12 December 2000 (2000-12-12)	1-9
	abstract; figure 4	
Y	WO 96 27899 A (IBM)	1-9
	12 September 1996 (1996-09-12)	
	page 2, paragraph 3 -page 3, paragraph 1	
Y	US 6 136 211 A (QIAN ET AL)	1-8
	24 October 2000 (2000-10-24) column 1, line 1 - line 61	
A	US 5 468 686 A (KAWAMOTO)	6,7
•	21 November 1995 (1995-11-21) column 3, line 1 - line 22	

LX		Further documents are listed in the	continuation of box C.
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X Patent family members are listed in annex.

- 'A' document defining the general state of the art which is not considered to be of particular relevance
- "E" earlier document but published on or after the International filing date
- "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)
- *O' document referring to an oral disclosure, use, exhibition or other means
- document published prior to the international filing date but later than the priority date claimed

Date of the actual completion of the international search

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- 'X' document of particular relevance; the claimed Invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
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Date of mailing of the international search report

'&' document member of the same patent family

17 July 2002

Name and mailing address of the ISA European Patent Office, P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl. Fex: (+31-70) 340-3016

25/07/2002

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Form PCT/ISA/210 (second enert) (July 1992)

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Special categories of cited documents:

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Category •	tion) DOCUMENTS CONSIDERED TO BE RELEVANT Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US 5 776 832 A (HSIEH ET AL) 7 July 1998 (1998-07-07) column 6, line 12 - line 14	1
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INTERNATIONAL SEARCH REPORT

information on patent family members

International Application No PCT/EP 02/02030

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US 6136211	A	24-10-2000	EP JP WO US	1029345 A1 2001523044 T 9925015 A1 6322714 B1	23-08-2000 20-11-2001 20-05-1999 27-11-2001
US 5468686	A	21-11-1995	JP JP KR	2674488 B2 7153746 A 145645 B1	12-11-1997 16-06-1995 02-11-1998
US 5776832	Α	07-07-1998	NONE		

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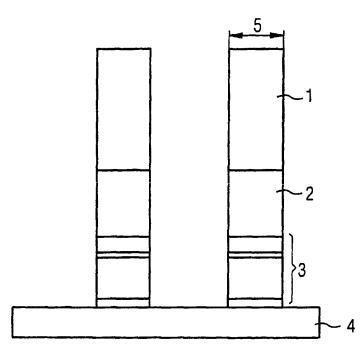
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Published:

- with international search report
- before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: METHOD FOR ETCHING A HARDMASK LAYER AND A METAL LAYER



(57) Abstract: The present invention relates to an improved insitu hardmask open strategy which is performed before carrying out a metal etch. The method for opening the hardmask (2) made of SiO2, Si3N4 or SiON comprises the steps of providing a substrate having thereon at least one metal layer (3), a hardmask layer made of SiO2, Si3N4 or SiON and a patterned photoresist layer overlying said hardmask layer (2), etching said hardmask layer (2) in a plasma etching process using an etchant source gas which comprises a fluorine containing gas and oxygen, wherein the plasma processing chamber used for etching the hardmask layer (2) is the same as the plasma processing chamber in which the at least one metal layer (3) is etched in another plasma etching process after the hardmask layer (2) has been etched.

WO 02/073682 A1

Docket # P2001,0126

Applic. #

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